



Model created in COMSOL Multiphysics 6.4

# 3D Analysis of a Bipolar Transistor

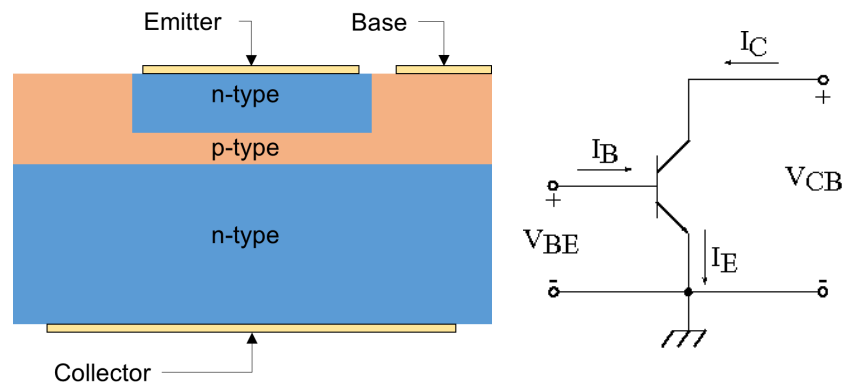


This model shows how to set up a 3D simulation of a NPN bipolar transistor. It is a 3D version of the device shown in the [Bipolar Transistor](#) model and demonstrates how to extend semiconductor modeling into 3D using COMSOL Multiphysics. As in the 2D version of this model, the device is simulated whilst operating in the common-emitter regime. A voltage-driven study is computed to characterize the current–voltage response of the device, and two current driven studies are performed to simulate the device operating as an analog current amplifier.

### Introduction

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Bipolar transistors rely on both electron and hole currents in order to function whereas unipolar transistors, such as MOSFET devices, operate utilizing only one species of carrier. Bipolar transistors have largely been replaced in integrated circuits by field-effect devices; however, they are still important in analog electronics — particularly in power control circuitry where they can be used as switches and current amplifiers.



*Figure 1: Left: Simplified cross section through a bipolar transistor showing the structure of the device. Right: Circuit diagram showing the common emitter configuration.*

A bipolar transistor consists of three regions known as the emitter, base, and collector. In an NPN transistor the p-type base region is sandwiched between the n-type emitter and collector regions, as shown in the left panel of [Figure 1](#). In the common emitter configuration the emitter contact is the common ground for both the base and collector contacts, that is, the base and collector voltages are measured relative to the emitter, which is grounded. This is shown schematically in the right panel of [Figure 1](#).

In normal operation, the base–emitter junction is under forward bias and the base–collector junction is under reverse bias. Electrons are injected over the forward bias p–n junction from the emitter into the base. They then diffuse through the base region as minority carriers. Those electrons which reach the base–collector junction are swept to the collector contact by the electric field of the depleted region near the reverse bias p–n junction.

The effective resistance between the emitter and collector can be varied by applying a current to the base. In this way, the collector–emitter current can be controlled by a smaller base–emitter current. In this configuration the device functions as a current amplifier, as the collector–emitter current (at a given collector–emitter voltage) is proportional to the base–emitter current. Typically, the current gain can have values of the order of 100 which makes bipolar transistors attractive in a wide range of power management circuitry. For example, a small current from some sensing circuitry, such as a photodiode or temperature probe, could be used to control a larger current needed to operate a motor or a heating element.

The model presented here performs a detailed DC current–voltage characterization of the bipolar transistor device. The current gain is computed as a function of the collector current, along with an emitter–collector I–V curve for fixed currents applied to the base.

### *Model Definition*

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The model geometry is shown in [Figure 2](#). Due to the symmetry of the device only one quarter of the whole structure is explicitly modeled. The modeled doping profile is shown in [Figure 3](#). As is typical of the profile used in silicon bipolar transistors, it consists of four regions (n+, p, n, and n+), described in detail in [Modeling Instructions](#).

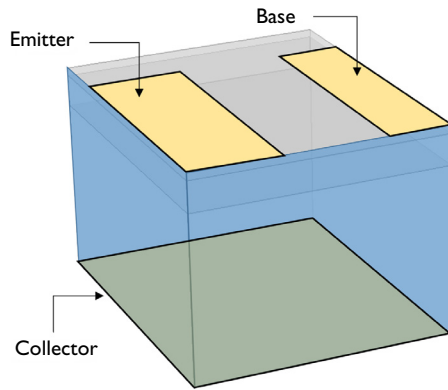


Figure 2: Model geometry, the symmetry planes are highlighted in blue and the boundaries to which the three electric contacts are applied are labeled.

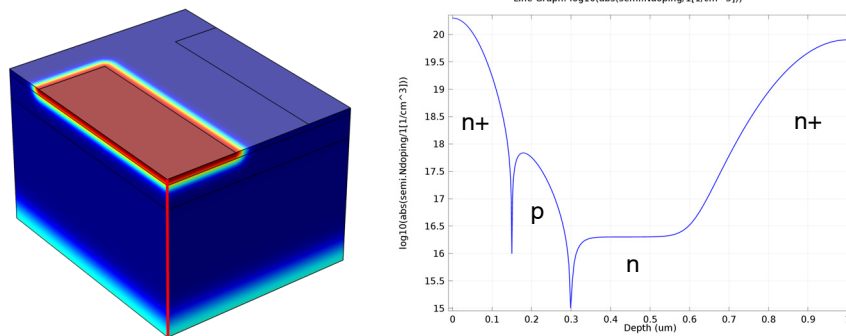


Figure 3: Dopant distribution for the bipolar transistor device. Left: Volume plot showing the total net dopant concentration, the emitter region can be clearly seen in red; the boundary between the base and collector is not apparent due to the large magnitude of the concentration in the n+ regions. Right: Line cut of the total net dopant concentration taken along the red line shown in the left-hand pane. The p-type base region can be seen in this plot.

The physics and studies settings in this model are exactly the same as in the 2D model [Bipolar Transistor](#).

### Results and Discussion

Figure 4 displays the current at each terminal as a function of the base-emitter voltage ( $V_{BE}$ ) for a fixed collector-emitter voltage ( $V_{CE} = 0.5$  V). Note that the figure shows the terminal currents using the COMSOL Multiphysics sign convention: current that flows

from the contact into the semiconductor is positive, and current that flows out of the semiconductor into the contact is negative. The figure also shows that the current is conserved. This can be seen as the sum of the base and collector currents have equal magnitude and opposite sign to the emitter current, i.e: the base current can be calculated from the other currents using

$$I_B = -(I_E + I_C)$$

The results are in good agreement with the 2D model [Bipolar Transistor](#). Note that when comparing 2D and 3D results, the total current should be scaled with reference to the effective thickness.

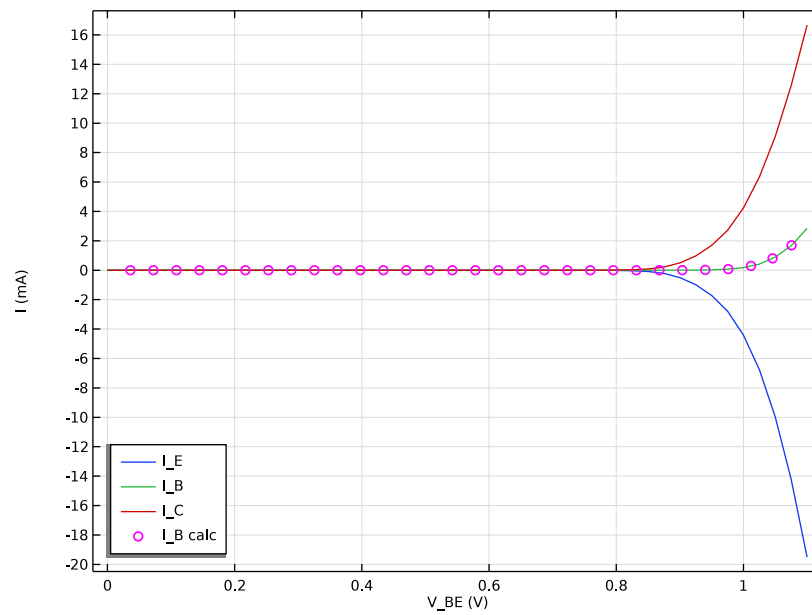


Figure 4: Terminal currents as a function of the base-emitter voltage ( $V_{BE}$ ) for a fixed collector-emitter voltage ( $V_{CE} = 0.5$  V).

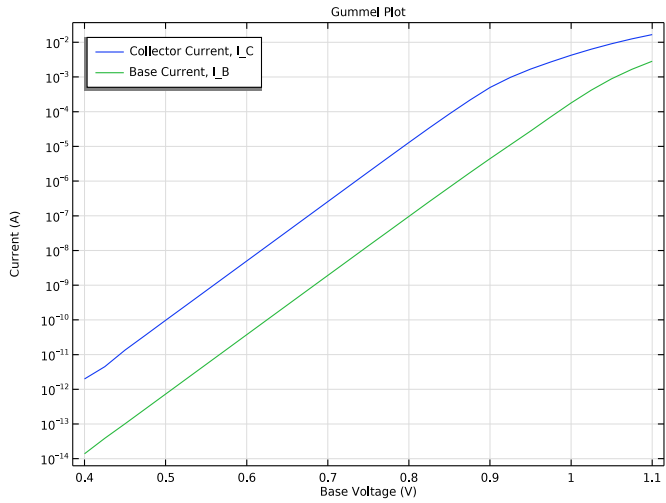


Figure 5: Gummel plot showing the magnitude of the collector and base current as a function of the base voltage.

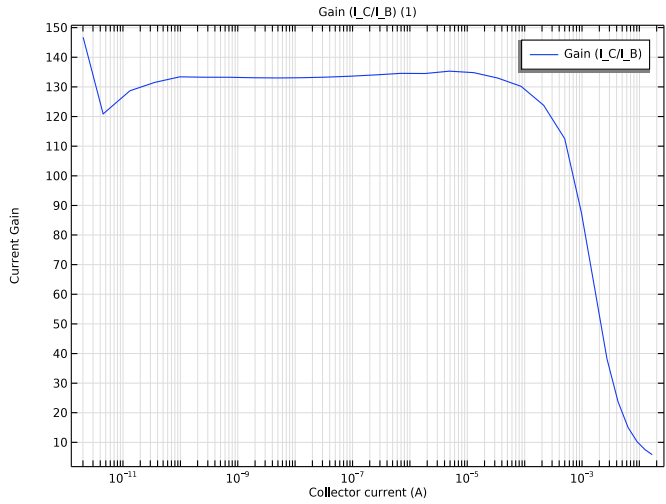


Figure 6: Current gain as a function of collector current for a fixed base voltage of  $V_{CE}=0.5$  V.

Figure 5 shows the Gummel plot for the modeled bipolar transistor. The Gummel plot shows the magnitude of the collector and base currents, plotted on a logarithmic scale, as a function of the base voltage.

Figure 6 shows the current gain, defined as  $I_C/I_B$ , as a function of the collector current at a fixed base voltage of  $V_{CE}=0.5$  V.

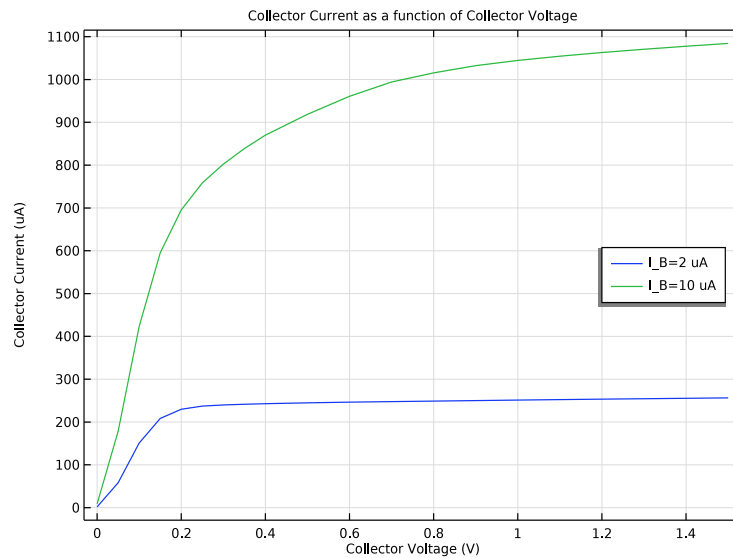
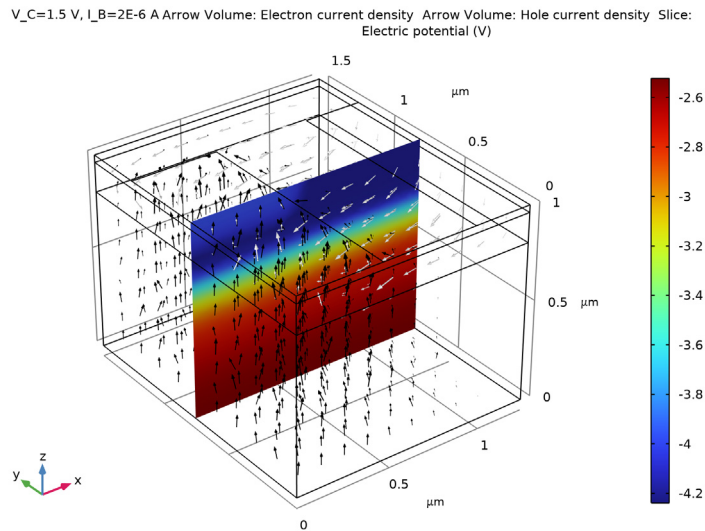


Figure 7: Plot of collector current vs. collector voltage for  $I_B = 2 \mu A$  and  $I_B = 10 \mu A$ . Note that varying the base current controls the resistance between the emitter and collector.

Figure 7 shows the collector current as a function of collector voltage for two different values of base current  $2 \mu A$  and  $10 \mu A$ . This figure shows the collector I–V curve for the device in the common emitter configuration. Initially the current increases linearly with increasing emitter–collector voltage, before reaching a saturation level. The gradient of the linear regime and the magnitude of the saturation current depend on the base current.

Figure 8 shows the voltage and carrier current densities throughout the device. With  $V_{CE} = 1.5$  V the device is in the forward-active regime. In this regime the emitter–base junction is forward biased and the base–collector junction is reverse biased. Electrons are injected from the emitter into the base through the forward biased junction. These electrons then diffuse through the p-type base region as minority carriers. Those that make it to the reverse biased base–collector junction are swept toward the collector terminal by the junction electric field. The thickness of the base region must be small enough to allow the electrons to diffuse through with high probability. Holes can travel easily from the base to the emitter regions through the forward biased emitter–base junction, but they cannot traverse the reverse biased base–collector junction. Hence the hole current flows between

the emitter and base terminals without entering the lower n-doped region, and the electron current flows between the emitter and collector terminals.



*Figure 8: Voltage and current density for  $I_B = 2 \mu A$  and  $V_{CE} = 1.5 V$ . The color shows the voltage and the arrows show the current density for electrons (black) and holes (white). Note that the hole current flows from the base to the emitter and does not enter the lower n-doped region, whilst the electron current flows between the collector and emitter. This current pattern is due to the two p-n junctions that form the device. The electric field is largest around the junctions, as can be seen by the rapid change in voltage between the differently doped regions.*

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**Application Library path:** Semiconductor\_Module/Transistors/  
bipolar\_transistor\_3d


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### *Modeling Instructions*




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From the **File** menu, choose **New**.

#### **NEW**

In the **New** window, click  **Model Wizard**.

## MODEL WIZARD

- 1 In the **Model Wizard** window, click  **3D**.
- 2 In the **Select Physics** tree, select **Semiconductor** > **Semiconductor (semi)**.
- 3 Click **Add**.
- 4 Click  **Study**.
- 5 In the **Select Study** tree, select **General Studies** > **Stationary**.
- 6 Click  **Done**.

## GLOBAL DEFINITIONS


Import the model parameters from bipolar\_transistor\_3d\_parameters.txt.

- 1 In the **Model Builder** window, click **Global Definitions**.
- 2 In the **Settings** window for Parameters, locate the **Parameters** section.
- 3 Browse to the model's Application Libraries folder and double-click the file bipolar\_transistor\_3d\_parameters.txt.


## GEOMETRY I

- 1 In the **Model Builder** window, under **Component 1 (comp1)** click **Geometry 1**.
- 2 In the **Settings** window for **Geometry**, locate the **Units** section.
- 3 From the **Length unit** list, choose  $\mu\text{m}$ .



*Block 1 (blk1)*

- 1 In the **Geometry** toolbar, click  **Block**.  
Add silicon as the material for the device.
- 2 In the **Settings** window for **Block**, locate the **Size and Shape** section.
- 3 In the **Width** text field, type  $w_{\text{BJT}}/2$ .
- 4 In the **Depth** text field, type  $l_{\text{BJT}}/2$ .
- 5 In the **Height** text field, type  $d_{\text{BJT}}$ .


*Block 2 (blk2)*

- 1 In the **Geometry** toolbar, click  **Block**.
- 2 In the **Settings** window for **Block**, locate the **Size and Shape** section.
- 3 In the **Width** text field, type  $w_{\text{BJT}}/2$ .
- 4 In the **Depth** text field, type  $l_{\text{BJT}}/2$ .
- 5 In the **Height** text field, type  $1*d_{\text{E}}$ .
- 6 Locate the **Position** section. In the **z** text field, type  $d_{\text{BJT}} - 1.25*d_{\text{E}}$ .


*Work Plane 1 (wp1)*

- 1 In the **Geometry** toolbar, click  **Work Plane**.
- 2 In the **Settings** window for **Work Plane**, locate the **Plane Definition** section.
- 3 In the **z-coordinate** text field, type  $d_{BJT}$ .
- 4 Click  **Go to Plane Geometry**.

*Work Plane 1 (wp1) > Rectangle 1 (r1)*

- 1 In the **Work Plane** toolbar, click  **Rectangle**.
- 2 In the **Settings** window for **Rectangle**, locate the **Size and Shape** section.
- 3 In the **Width** text field, type  $w_{cE}$ .
- 4 In the **Height** text field, type  $l_E/2 - 2*d_E$ .



*Work Plane 1 (wp1) > Rectangle 2 (r2)*

- 1 In the **Work Plane** toolbar, click  **Rectangle**.
- 2 In the **Settings** window for **Rectangle**, locate the **Size and Shape** section.
- 3 In the **Width** text field, type  $w_{BJT}/2 - w_{EB} - w_E/2$ .
- 4 In the **Height** text field, type  $l_{cB}/2 - 2*d_E$ .
- 5 Locate the **Position** section. In the **xw** text field, type  $w_{BJT}/2 - w_{cB}$ .
- 6 In the **Model Builder** window, right-click **Geometry 1** and choose **Build All**.

#### **SEMICONDUCTOR (SEMI)**

- 1 In the **Model Builder** window, under **Component 1 (comp1)** click **Semiconductor (semi)**.
- 2 In the **Settings** window for **Semiconductor**, click to expand the **Discretization** section.
- 3 From the **Formulation** list, choose **Finite element, log formulation (linear shape function)**.

#### **ADD MATERIAL**

- 1 In the **Home** toolbar, click  **Add Material** to open the **Add Material** window.
- 2 Go to the **Add Material** window.
- 3 In the tree, select **Semiconductors > Si - Silicon**.
- 4 Click the **Add to Component** button in the window toolbar.
- 5 In the **Home** toolbar, click  **Add Material** to close the **Add Material** window.

## MATERIALS


*Si - Silicon (mat1)*

Now the physics can be configured for the model. The first step is to create the required dopant distribution. This is achieved using four **Analytic Doping Model** features, one to specify a constant background level and then one for each of the emitter, base, and collector regions.


Add a constant background n-doping to the device.

## SEMICONDUCTOR (SEMI)

*Constant Background n Doping*

- 1 In the **Physics** toolbar, click  **Domains** and choose **Analytic Doping Model**.
- 2 In the **Settings** window for **Analytic Doping Model**, locate the **Domain Selection** section.
- 3 From the **Selection** list, choose **All domains**.
- 4 Locate the **Impurity** section. From the **Impurity type** list, choose **Donor doping (n-type)**.
- 5 In the  $N_{D0}$  text field, type  $N_{\text{epi}}$ .
- 6 In the **Label** text field, type Constant Background n Doping.

*Base p Doping*

- 1 In the **Physics** toolbar, click  **Domains** and choose **Analytic Doping Model**.  
Add a layer of p-type doping to for the base region.
- 2 In the **Settings** window for **Analytic Doping Model**, locate the **Domain Selection** section.
- 3 From the **Selection** list, choose **All domains**.
- 4 Locate the **Distribution** section. From the list, choose **Box**.
- 5 Locate the **Impurity** section. In the  $N_{A0}$  text field, type  $N_{\text{B}}+N_{\text{epi}}$ .
- 6 Locate the **Uniform Region** section. Specify the  $r_0$  vector as

0 [um]	X
0 [um]	Y
d_BJT-d_E	Z

- 7 In the  $W$  text field, type  $w_{\text{BJT}}/2$ .
- 8 In the  $D$  text field, type  $1_{\text{cB}}/2$ .
- 9 In the  $H$  text field, type  $d_{\text{E}}$ .
- 10 Locate the **Profile** section. In the  $d_j$  text field, type  $d_{\text{E}}$ .

11 From the  $N_b$  list, choose **Donor concentration (semi/adm1)**.

12 In the **Label** text field, type Base p Doping.

#### *Emitter n Doping*

1 In the **Physics** toolbar, click  **Domains** and choose **Analytic Doping Model**.

Add an n-type region for the emitter.

2 In the **Settings** window for **Analytic Doping Model**, locate the **Domain Selection** section.

3 From the **Selection** list, choose **All domains**.

4 Locate the **Distribution** section. From the list, choose **Box**.

5 Locate the **Impurity** section. From the **Impurity type** list, choose **Donor doping (n-type)**.

6 In the  $N_{D0}$  text field, type  $N_E + N_B$ .

7 Locate the **Uniform Region** section. Specify the  $r_0$  vector as

0[um]	X
0[um]	Y
d_BJT	Z

8 In the  $W$  text field, type  $w_E/2 - d_E$ .

9 In the  $D$  text field, type  $l_E/2 - 2*d_E$ .

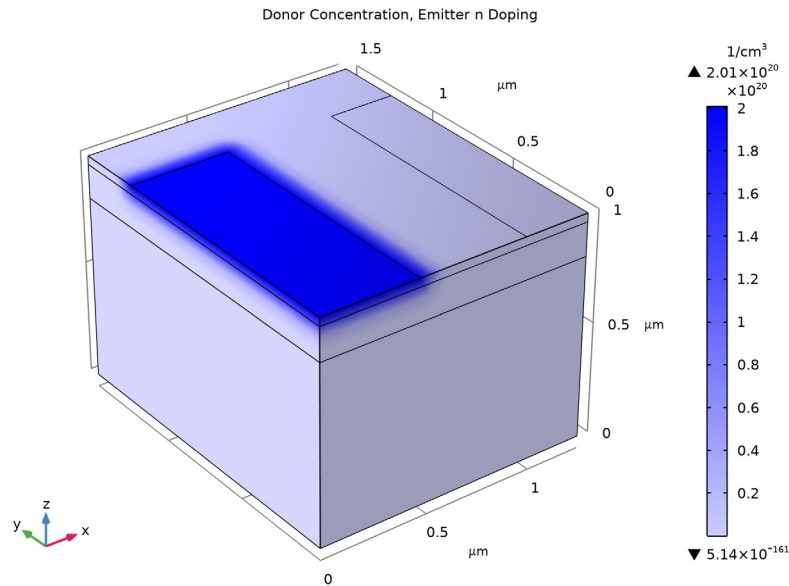
10 Locate the **Profile** section. In the  $d_j$  text field, type  $d_E$ .

11 In the  $N_b$  text field, type  $N_B$ .

12 In the **Label** text field, type Emitter n Doping.


Here you can plot the preview of the doping profile for the selected feature.

13 Click the **Plot Doping Profile for Selected** button in the window toolbar.



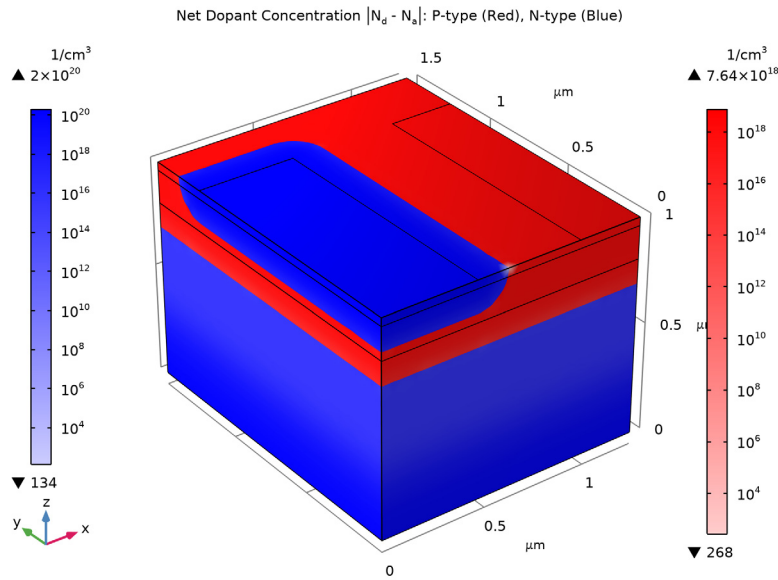
Add another n-type region for the collector.

#### Collector n Doping

- 1 In the **Physics** toolbar, click  **Domains** and choose **Analytic Doping Model**.
- 2 In the **Settings** window for **Analytic Doping Model**, locate the **Domain Selection** section.
- 3 From the **Selection** list, choose **All domains**.
- 4 Locate the **Distribution** section. From the list, choose **Box**.
- 5 Locate the **Impurity** section. From the **Impurity type** list, choose **Donor doping (n-type)**.
- 6 In the  $N_{D0}$  text field, type  $N_C$ .
- 7 Locate the **Uniform Region** section. In the  $W$  text field, type  $w_{BJT}/2$ .
- 8 In the  $D$  text field, type  $1_{BJT}/2$ .
- 9 Locate the **Profile** section. In the  $d_j$  text field, type  $1.3*d_C$ .
- 10 From the  $N_b$  list, choose **Donor concentration (semi/adm1)**.
- 11 In the **Label** text field, type Collector n Doping.

Here you can plot the preview of the doping profile for all the features.

12 Click the **Plot Net Doping Profile for All** button in the window toolbar.



Add a **Trap-Assisted Recombination** feature to the model.

*Trap-Assisted Recombination 1*

- 1 In the **Physics** toolbar, click **Domains** and choose **Trap-Assisted Recombination**.
- 2 In the **Settings** window for **Trap-Assisted Recombination**, locate the **Domain Selection** section.
- 3 From the **Selection** list, choose **All domains**.

Next add **Metal Contact** features to define the emitter, base, and collector contacts.

*Emitter Voltage*


- 1 In the **Physics** toolbar, click **Boundaries** and choose **Metal Contact**.
- 2 Select Boundary 10 only.
- 3 In the **Settings** window for **Metal Contact**, locate the **Terminal** section.
- 4 In the  $V_0$  text field, type  $V_E$ .
- 5 In the **Label** text field, type Emitter Voltage.

*Base Voltage*

- 1 In the **Physics** toolbar, click **Boundaries** and choose **Metal Contact**.

- 2 Select Boundary 15 only.
- 3 In the **Settings** window for **Metal Contact**, locate the **Terminal** section.
- 4 In the  $V_0$  text field, type  $V_B$ .
- 5 In the **Label** text field, type Base Voltage.

#### *Collector Voltage*

- 1 In the **Physics** toolbar, click  **Boundaries** and choose **Metal Contact**.
- 2 Select Boundary 3 only.
- 3 In the **Settings** window for **Metal Contact**, locate the **Terminal** section.
- 4 In the  $V_0$  text field, type  $V_C$ .
- 5 In the **Label** text field, type Collector Voltage.

As well as applying a voltage to all three contacts, this model also requires the application of a current to the base and collector contacts. This is achieved by duplicating each of the respective voltage-applying contacts and selecting to apply a current. In each study the relevant contact boundary conditions are chosen by selectively disabling the features which are not required.

#### *Base Current*

- 1 In the **Model Builder** window, right-click **Base Voltage** and choose **Duplicate**.
- 2 In the **Settings** window for **Metal Contact**, locate the **Terminal** section.
- 3 From the **Terminal type** list, choose **Current**.
- 4 In the  $I_0$  text field, type  $I_B$ .
- 5 In the **Label** text field, type Base Current.

#### **MESH 1**


- 1 In the **Model Builder** window, under **Component 1 (comp1)** click **Mesh 1**.
- 2 In the **Settings** window for **Mesh**, locate the **Sequence Type** section.
- 3 From the list, choose **User-controlled mesh**.

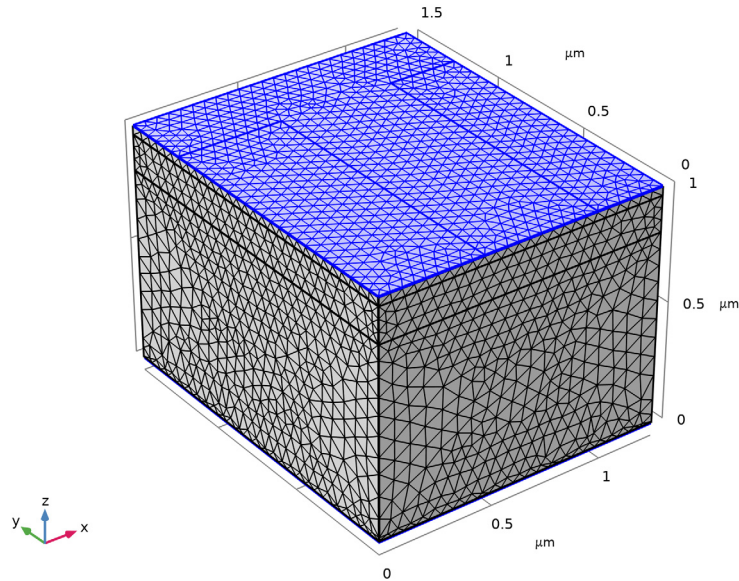
#### *Boundary Layers 1*

In the **Mesh** toolbar, click  **Boundary Layers**.

#### *Boundary Layer Properties*

- 1 In the **Model Builder** window, click **Boundary Layer Properties**.
- 2 Select Boundaries 3, 10, 11, and 15 only.
- 3 In the **Settings** window for **Boundary Layer Properties**, locate the **Layers** section.

- 4 In the **Stretching factor** text field, type 1.5.
- 5 From the **Thickness specification** list, choose **First layer**.
- 6 In the **Thickness** text field, type 1e-4.
- 7 Click  **Build All**.



First, perform a Stationary Study to sweep the collector voltage. The solution will be used as initial values by the next study.

**V\_C SWEEP, V\_B=0 V, V\_E=0 V**

- 1 In the **Model Builder** window, click **Study I**.
- 2 In the **Settings** window for **Study**, type V\_C Sweep, V\_B=0 V, V\_E=0 V in the **Label** text field.
- 3 Locate the **Study Settings** section. Clear the **Generate default plots** checkbox.

*Step 1: Stationary*

- 1 In the **Model Builder** window, under **V\_C Sweep, V\_B=0 V, V\_E=0 V** click **Step 1: Stationary**.
- 2 In the **Settings** window for **Stationary**, click to collapse the **Study Settings** section.
- 3 Click to expand the **Study Settings** section. Locate the **Physics and Variables Selection** section. Select the **Modify model configuration for study step** checkbox.

- 4 In the tree, select **Component 1 (comp1) > Semiconductor (semi) > Base Current**.
- 5 Right-click and choose **Disable**.
- 6 Click to expand the **Study Extensions** section. Select the **Auxiliary sweep** checkbox.
- 7 From the **Sweep type** list, choose **All combinations**.
- 8 Click **+ Add**.
- 9 In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
V_B (Applied voltage: base)	0	V

- 10 Click **+ Add**.

- 11 In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
V_E (Applied voltage: emitter)	0	V

- 12 Click **+ Add**.



- 13 In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
V_C (Applied voltage: collector)	range (0, 0.1, 0.5)	V

- 14 In the **Study** toolbar, click **= Compute**.

Next, add a Stationary Study to perform a sweep of the base voltage.

#### ADD STUDY

- 1 In the **Study** toolbar, click  **Add Study** to open the **Add Study** window.
- 2 Go to the **Add Study** window.
- 3 Find the **Studies** subsection. In the **Select Study** tree, select **General Studies > Stationary**.
- 4 Click the **Add Study** button in the window toolbar.
- 5 In the **Study** toolbar, click  **Add Study** to close the **Add Study** window.

#### V\_B SWEEP, V\_C=0.5 V, V\_E=0 V

- 1 In the **Settings** window for **Study**, type V\_B Sweep, V\_C=0.5 V, V\_E=0 V in the **Label** text field.
- 2 Locate the **Study Settings** section. Clear the **Generate default plots** checkbox.

Define the sweep for the full base voltage (V<sub>B</sub>) study.

- 1 In the **Model Builder** window, under **V<sub>B</sub> Sweep, V<sub>C</sub>=0.5 V, V<sub>E</sub>=0 V** click **Step 1: Stationary**.
- 2 In the **Settings** window for **Stationary**, locate the **Physics and Variables Selection** section.
- 3 Select the **Modify model configuration for study step** checkbox.
- 4 In the tree, select **Component 1 (comp1) > Semiconductor (semi) > Base Current**.
- 5 Right-click and choose **Disable**.
- 6 Click to expand the **Values of Dependent Variables** section. Find the **Initial values of variables solved for** subsection. From the **Settings** list, choose **User controlled**.
- 7 From the **Method** list, choose **Solution**.
- 8 From the **Study** list, choose **V<sub>C</sub> Sweep, V<sub>B</sub>=0 V, V<sub>E</sub>=0 V, Stationary**.
- 9 From the **Parameter value (V<sub>C</sub> (V),V<sub>B</sub> (V),V<sub>E</sub> (V))** list, choose **Last**.
- 10 Locate the **Study Extensions** section. Select the **Auxiliary sweep** checkbox.
- 11 Click **+ Add**.
- 12 In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
V <sub>B</sub> (Applied voltage: base)	range (0, 0.025, 1.1)	V

- 13 In the **Study** toolbar, click **= Compute**.

Plot the current at each terminal as a function of the base voltage (V<sub>B</sub>). Note that currents which flow from the contact into the semiconductor have positive sign and those which flow from the semiconductor into a contact have negative sign.

## RESULTS

### *ID Plot Group 1*

- 1 In the **Results** toolbar, click **~ ID Plot Group**.
- 2 In the **Settings** window for **ID Plot Group**, locate the **Data** section.
- 3 From the **Dataset** list, choose **V<sub>B</sub> Sweep, V<sub>C</sub>=0.5 V, V<sub>E</sub>=0 V/Solution 2 (sol2)**.

### *Global 1*

- 1 Right-click **ID Plot Group 1** and choose **Global**.

- 2 In the **Settings** window for **Global**, click **Replace Expression** in the upper-right corner of the **y-Axis Data** section. From the menu, choose **Component I (comp1) > Semiconductor > Terminals > semi.I0\_1 - Terminal current - A**.
- 3 Click **Add Expression** in the upper-right corner of the **y-Axis Data** section. From the menu, choose **Component I (comp1) > Semiconductor > Terminals > semi.I0\_2 - Terminal current - A**.
- 4 Click **Add Expression** in the upper-right corner of the **y-Axis Data** section. From the menu, choose **Component I (comp1) > Semiconductor > Terminals > semi.I0\_3 - Terminal current - A**.
- 5 Locate the **y-Axis Data** section. In the table, enter the following settings:

Expression	Unit	Description
semi.I0_1	mA	I_E
semi.I0_2	mA	I_B
semi.I0_3	mA	I_C

- 6 In the **ID Plot Group 1** toolbar, click  **Plot**.

The current is conserved. To see this, add a plot of  $I_B = -(I_E + I_C)$  to the graph, which, due to the software sign convention, corresponds with emitter current being equal to the sum of the base and collector currents.

#### Global 2


- 1 In the **Model Builder** window, right-click **ID Plot Group 1** and choose **Global**.
- 2 In the **Settings** window for **Global**, locate the **y-Axis Data** section.
- 3 In the table, enter the following settings:

Expression	Unit	Description
$-(\text{semi.I0}_1 + \text{semi.I0}_3)$	mA	I_B calc

- 4 Click to expand the **Coloring and Style** section. Find the **Line style** subsection. From the **Line** list, choose **None**.
- 5 From the **Color** list, choose **Magenta**.
- 6 Find the **Line markers** subsection. From the **Marker** list, choose **Circle**.
- 7 From the **Positioning** list, choose **Interpolated**.
- 8 In the **Number** text field, type 30.


#### *I\_E, I\_B and I\_C as a function of V\_BE*

- 1 In the **Model Builder** window, click **ID Plot Group 1**.

- 2 In the **Settings** window for **ID Plot Group**, click to expand the **Title** section.
- 3 From the **Title type** list, choose **None**.
- 4 Locate the **Plot Settings** section. Select the **x-axis label** checkbox.
- 5 Select the **y-axis label** checkbox.
- 6 In the **x-axis label** text field, type  $V_{BE}$  (V).
- 7 In the **y-axis label** text field, type  $I$  (mA).
- 8 Locate the **Legend** section. From the **Position** list, choose **Lower left**.
- 9 In the **ID Plot Group 1** toolbar, click  **Plot**.
- 10 In the **Label** text field, type  $I_E$ ,  $I_B$  and  $I_C$  as a function of  $V_{BE}$ .

Plot the collector and base currents as a function of the base-emitter voltage. This kind of plot is known as a Gummel plot, and is useful in device characterization.

#### *ID Plot Group 2*

- 1 In the **Results** toolbar, click  **ID Plot Group**.
- 2 In the **Settings** window for **ID Plot Group**, locate the **Data** section.
- 3 From the **Dataset** list, choose **V\_B Sweep, V\_C=0.5 V, V\_E=0 V/Solution 2 (sol2)**.



#### *Global 1*

- 1 Right-click **ID Plot Group 2** and choose **Global**.
- 2 In the **Settings** window for **Global**, locate the **y-Axis Data** section.
- 3 In the table, enter the following settings:

Expression	Unit	Description
abs(semi.I0_3)	A	Collector Current, $I_C$
abs(semi.I0_2)	A	Base Current, $I_B$


#### *Gummel Plot, $I_C$ and $I_B$ as a function of $V_{BE}$*

- 1 In the **Model Builder** window, click **ID Plot Group 2**.
- 2 In the **Settings** window for **ID Plot Group**, locate the **Legend** section.
- 3 From the **Position** list, choose **Upper left**.
- 4 Locate the **Title** section. From the **Title type** list, choose **Manual**.
- 5 In the **Title** text area, type Gummel Plot.
- 6 Locate the **Plot Settings** section.
- 7 Select the **x-axis label** checkbox. In the associated text field, type Base Voltage (V).
- 8 Select the **y-axis label** checkbox. In the associated text field, type Current (A).

- 9 Click the  **y-Axis Log Scale** button in the **Graphics** toolbar.  
Restrict the data range to exclude very small current values.
- 10 Locate the **Data** section. From the **Parameter selection (V\_B)** list, choose **Manual**.
- 11 In the **Parameter indices (1-45)** text field, type range (17, 1, 45).
- 12 In the **ID Plot Group 2** toolbar, click  **Plot**.
- 13 In the **Label** text field, type Gummel Plot, I\_C and I\_B as a function of V\_BE.

Another useful characterization quantity is the DC current gain curve, which is the ratio of the collector to base current ( $I_C/I_B$ ) as a function of collector current.

#### *ID Plot Group 3*

- 1 In the **Results** toolbar, click  **ID Plot Group**.
- 2 In the **Settings** window for **ID Plot Group**, locate the **Data** section.
- 3 From the **Dataset** list, choose **V\_B Sweep, V\_C=0.5 V, V\_E=0 V/Solution 2 (sol2)**.
- 4 Locate the **Axis** section. Select the **x-axis log scale** checkbox.


#### *Global 1*

- 1 Right-click **ID Plot Group 3** and choose **Global**.
- 2 In the **Settings** window for **Global**, locate the **y-Axis Data** section.
- 3 In the table, enter the following settings:

Expression	Unit	Description
$\text{abs}(\text{semi.I0}_3/\text{semi.I0}_2)$	1	Gain ( $I_C/I_B$ )

- 4 Locate the **x-Axis Data** section. From the **Parameter** list, choose **Expression**.
- 5 In the **Expression** text field, type  $\text{semi.I0}_3$ .

#### *Current Gain*

- 1 In the **Model Builder** window, click **ID Plot Group 3**.
- 2 In the **Settings** window for **ID Plot Group**, locate the **Plot Settings** section.
- 3 Select the **x-axis label** checkbox. In the associated text field, type Collector current (A).
- 4 Select the **y-axis label** checkbox. In the associated text field, type Current Gain.  
Restrict the data range to exclude very small current values.
- 5 Locate the **Data** section. From the **Parameter selection (V\_B)** list, choose **Manual**.
- 6 In the **Parameter indices (1-45)** text field, type range (17, 1, 45).
- 7 In the **ID Plot Group 3** toolbar, click  **Plot**.

8 In the **Label** text field, type **Current Gain**.

The collector current as a function of the collector voltage can be controlled by applying a base current. In this way, the output characteristics of the device can be controlled by an input current from, say, a sensing circuit. This effect can be seen by plotting the collector current as a function of the collector voltage for two different values of the base current.



As the required studies are current driven it is helpful to provide good initial values.

## SEMICONDUCTOR (SEMI)

### Base Current

- 1 In the **Model Builder** window, under **Component 1 (comp1) > Semiconductor (semi)** click **Base Current**.
- 2 In the **Settings** window for **Metal Contact**, locate the **Terminal** section.
- 3 In the  $V_{init}$  text field, type **0.8[V]**.

## ADD STUDY

- 1 In the **Home** toolbar, click  **Add Study** to open the **Add Study** window.
- 2 Go to the **Add Study** window.
- 3 Find the **Studies** subsection. In the **Select Study** tree, select **General Studies > Stationary**.
- 4 Click the **Add Study** button in the window toolbar.
- 5 In the **Home** toolbar, click  **Add Study** to close the **Add Study** window.

## V\_C SWEEP, V\_E=0 V, FOR I\_B=2[uA]

- 1 In the **Settings** window for **Study**, type **V\_C Sweep, V\_E=0 V, for I\_B=2[uA]** in the **Label** text field.
- 2 Locate the **Study Settings** section. Clear the **Generate default plots** checkbox.

### Step 1: Stationary

- 1 In the **Model Builder** window, under **V\_C Sweep, V\_E=0 V, for I\_B=2[uA]** click **Step 1: Stationary**.
- 2 In the **Settings** window for **Stationary**, locate the **Values of Dependent Variables** section.
- 3 Find the **Initial values of variables solved for** subsection. From the **Settings** list, choose **User controlled**.
- 4 From the **Method** list, choose **Solution**.
- 5 From the **Study** list, choose **V\_B Sweep, V\_C=0.5 V, V\_E=0 V, Stationary**.
- 6 From the **Parameter value (V\_B (V))** list, choose **0.85 V**.

7 Locate the **Study Extensions** section. Select the **Auxiliary sweep** checkbox.

8 From the **Sweep type** list, choose **All combinations**.

9 Click **+ Add**.

10 In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
I_B (Inward applied current: base)	2 [uA]	A

11 Click **+ Add**.

12 In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
V_C (Applied voltage: collector)	range (0, 0.05, 0.4) range (0.5, 0.1, 1.5)	V

13 In the **Study** toolbar, click **= Compute**.

To investigate the effect that a larger base current has on the response of the collector current to the collector voltage sweep a similar study will be performed with a base current of 10 uA.

The study is the same as the previous one, but the base current (I\_B) is set to a value of 10 uA instead of 2 uA.

#### ADD STUDY

1 In the **Study** toolbar, click  **Add Study** to open the **Add Study** window.

2 Go to the **Add Study** window.

3 Find the **Studies** subsection. In the **Select Study** tree, select **Empty Study**.

4 Click the **Add Study** button in the window toolbar.

5 In the **Study** toolbar, click  **Add Study** to close the **Add Study** window.

#### V\_C SWEEP, V\_E=0 V, FOR I\_B=10[UA]

1 In the **Settings** window for **Study**, locate the **Study Settings** section.

2 Clear the **Generate default plots** checkbox.

3 In the **Label** text field, type V\_C Sweep, V\_E=0 V, for I\_B=10[uA].

#### V\_C SWEEP, V\_E=0 V, FOR I\_B=2[UA]


Right-click **Step 1: Stationary** and choose **Copy**.

### V\_C SWEEP, V\_E=0 V, FOR I\_B=10[uA]

In the **Model Builder** window, right-click **V\_C Sweep, V\_E=0 V, for I\_B=10[uA]** and choose **Paste Stationary**.

- 1 In the **Settings** window for **Stationary**, locate the **Study Extensions** section.
- 2 In the table, enter the following settings:


Parameter name	Parameter value list	Parameter unit
I_B (Inward applied current: base)	10[uA]	A

- 3 In the **Study** toolbar, click  **Compute**.

Plotting both curves on the same graph allows for direct comparison.

## RESULTS

### *Common-emitter output characteristics*

- 1 In the **Results** toolbar, click  **ID Plot Group**.
- 2 Right-click **ID Plot Group 4** and choose **Rename**.
- 3 In the **Rename ID Plot Group** dialog, type **Common-emitter output characteristics** in the **New label** text field.
- 4 Click **OK**.

### *Global I*

- 1 Right-click **Common-emitter output characteristics** and choose **Global**.
- 2 In the **Settings** window for **Global**, locate the **Data** section.
- 3 From the **Dataset** list, choose **V\_C Sweep, V\_E=0 V, for I\_B=2[uA]/Solution 3 (sol3)**.
- 4 Locate the **y-Axis Data** section. In the table, enter the following settings:

Expression	Unit	Description
abs(semi.I0_3)	uA	Collector Current I_B=2uA

- 5 Click to expand the **Legends** section. From the **Legends** list, choose **Manual**.
- 6 In the table, enter the following settings:

Legends
I_B=2 uA

### Global 2


- 1 In the **Model Builder** window, right-click **Common-emitter output characteristics** and choose **Global**.
- 2 In the **Settings** window for **Global**, locate the **Data** section.
- 3 From the **Dataset** list, choose **V\_C Sweep, V\_E=0 V, for I\_B=10[uA]/Solution 4 (sol4)**.
- 4 Locate the **y-Axis Data** section. In the table, enter the following settings:

Expression	Unit	Description
abs(semi.I0_3)	uA	Collector Current I_B=10 uA


- 5 Locate the **Legends** section. From the **Legends** list, choose **Manual**.
- 6 In the table, enter the following settings:

Legends
I_B=10 uA

### Common-emitter output characteristics

- 1 In the **Model Builder** window, click **Common-emitter output characteristics**.
- 2 In the **Settings** window for **ID Plot Group**, locate the **Title** section.
- 3 From the **Title type** list, choose **Manual**.
- 4 In the **Title** text area, type Collector Current as a function of Collector Voltage.
- 5 Locate the **Plot Settings** section.
- 6 Select the **x-axis label** checkbox. In the associated text field, type Collector Voltage (V).
- 7 Select the **y-axis label** checkbox. In the associated text field, type Collector Current (uA).
- 8 Locate the **Legend** section. From the **Position** list, choose **Middle right**.
- 9 In the **Common-emitter output characteristics** toolbar, click  **Plot**.

### Current Density

- 1 In the **Results** toolbar, click  **3D Plot Group**.
- 2 In the **Settings** window for **3D Plot Group**, type Current Density in the **Label** text field.
- 3 Locate the **Data** section. From the **Dataset** list, choose **V\_C Sweep, V\_E=0 V, for I\_B=2[uA]/Solution 3 (sol3)**.

#### Arrow Volume 1



- 1 Right-click **Current Density** and choose **Arrow Volume**.
- 2 In the **Settings** window for **Arrow Volume**, locate the **Expression** section.
- 3 In the **X-component** text field, type  $\text{semi.JnX}$ .
- 4 In the **Y-component** text field, type  $\text{semi.JnY}$ .
- 5 In the **Z-component** text field, type  $\text{semi.JnZ}$ .
- 6 Locate the **Arrow Positioning** section. Find the **X grid points** subsection. In the **Points** text field, type 10.
- 7 Find the **Y grid points** subsection. In the **Points** text field, type 10.
- 8 Find the **Z grid points** subsection. In the **Points** text field, type 10.
- 9 Locate the **Coloring and Style** section. From the **Arrow length** list, choose **Logarithmic**.
- 10 From the **Color** list, choose **Black**.

#### Arrow Volume 2

- 1 Right-click **Arrow Volume 1** and choose **Duplicate**.
- 2 In the **Settings** window for **Arrow Volume**, locate the **Expression** section.
- 3 In the **X-component** text field, type  $\text{semi.JpX}$ .
- 4 In the **Y-component** text field, type  $\text{semi.JpY}$ .
- 5 In the **Z-component** text field, type  $\text{semi.JpZ}$ .
- 6 Locate the **Coloring and Style** section. From the **Color** list, choose **White**.

To aid in understanding the current flow throughout the device it is useful to add a slice plot of the voltage to highlight the emitter-base and base-collector junctions.

#### Slice 1

- 1 In the **Model Builder** window, right-click **Current Density** and choose **Slice**.
- 2 Click the  **Go to Default View** button in the **Graphics** toolbar.
- 3 In the **Settings** window for **Slice**, locate the **Plane Data** section.
- 4 From the **Plane** list, choose **ZX-planes**.
- 5 In the **Planes** text field, type 1.
- 6 Locate the **Expression** section. In the **Expression** text field, type  $V$ .
- 7 In the **Current Density** toolbar, click  **Plot**.

The value of  $V_C$  for which the final plot group is plotted can be changed in order to investigate the operation of the bipolar transistor. To do this, click on **Current Density** in

the Model Builder, locate the **Data** section of the **3D plot group** panel and change the value of **Parameter value (V\_C)**.

At  $V_C = 0$  V the electron and hole currents flow in unison from the base contact to both the collector and emitter contacts. This is expected, as the device is being driven by a base current. The net collector current is very small as the electron and hole currents are nearly balanced.

At  $V_C = 1.5$  V the device is operating in the saturation regime. The hole current flows mainly from the base to the emitter and the electron current flows mainly from the collector to the emitter. This results in a large net current at the collector contact.